



PATENT APPLICATION *IFW*

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Sadayoshi HORII et al.

ATTN: **OIPE**

Application No.: 10/529,466

Docket No.: 123373

Filed: March 29, 2005

For: **MANUFACTURING METHOD OF SEMICONDUCTOR DEVICE AND
SUBSTRATE PROCESSING APPARATUS**

CORRECTED FILING RECEIPT STATUS REQUEST

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

A Request for Correction of PALM Records was filed on October 17, 2005, and a subsequent Request was filed on November 16, 2006. Copies of the Requests and the Patent Office date-stamped acknowledgement receipts are attached hereto.

The corrected Filing Receipt has not yet been received. It is respectfully requested that the corrected Filing Receipt be immediately forwarded to the attorneys of record at the address set forth below. *re*

If there are any questions regarding this matter, please contact the undersigned at the telephone number set forth below.

Respectfully submitted,

James A. Oliff
Registration No. 27,075

Benjamin S. Prebyl
Registration No. 60,256

JAO:BSP/amw

Date: May 19, 2008

OLIFF & BERRIDGE, PLC
P.O. Box 320850
Alexandria, Virginia 22320-4850
Telephone: (703) 836-6400

**PTO RECEIPT FOR FILING OF PAPERS**

Delivery ▶ Mail Room

The following papers have been filed:Corrected Filing Receipt Status Request (Second Request); Copy of 10/17/05 OFR
Correction Request; Date-Stamped PTO Postcard Receipt

Name of Applicant:	Sadayoshi HORII; Hironobu MIYA
Serial No.:	10/529,466
Attorney File No.:	123373
Title:	Manufacturing Method of Semiconductor Device and Substrate Processing Apparatus
Sender's Initials:	JAO:KKV/KAM
Assignee:	HITACHI KOKUSAI ELECTRIC INC.

PATENT OFFICE DATE STAMP

76

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AND RETURNED BY MESSENGER**



PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Sadayoshi HORII et al.

ATTN: Application Branch

Application No.: 10/529,466

Docket No.: 123373

Filed: May 2, 2005

For: MANUFACTURING METHOD OF SEMICONDUCTOR DEVICE AND
SUBSTRATE PROCESSING APPARATUS

CORRECTED FILING RECEIPT STATUS REQUEST (SECOND REQUEST)

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

The above-identified application satisfied the requirements of 35 U.S.C. §371 on May 2, 2005, and was accorded U.S. Application No. 10/529,466. Applicants filed a Request for Correction of PALM Records on October 17, 2005 to reflect the May 2, 2005 §371(c) date and to correct the title (copy enclosed). However, Applicants to date have not received a Corrected Official Filing Receipt.

Applicants hereby request that a Corrected Official Filing Receipt be promptly forwarded to Applicants' representative.

Respectfully submitted,

James A. Oliff
Registration No. 27,075
Kristin K. Vidovich
Registration No. 41,448

JAO:KKV/kam

Date: November 15, 2006

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PTO RECEIPT FOR FILING OF PAPERS

► Mail Room (Regular Delivery)

The following papers have been filed:

Request for Correction of PALM Records; Marked-up OFR; Prelim

Name of Applicant: Sadayoshi HORII et al.

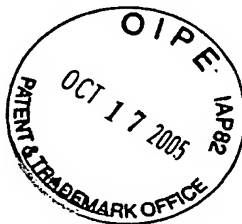
Serial No.: 10/529,466

Atty. File No.: 123373

Title (New Cases):

Sender's Initials: JAO/yxm

PATENT OFFICE DATE STAMP



40/13

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AND RETURNED BY MESSENGER**

Oloff & Berridge, PLC
277 S. Washington Street, Suite 500, Alexandria, Virginia 22314

S



PATENT APPLICATION

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Attn: OIPE

Sadayoshi HORII et al.

Application No.: 10/529,466

Docket No.: 123373

Filed: May 2, 2005

For: MANUFACTURING METHOD OF SEMICONDUCTOR DEVICE AND
SUBSTRATE PROCESSING APPARATUS

REQUEST FOR CORRECTION OF PALM RECORDS

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

Attached is a photocopy of the original filing receipt on which errors have been corrected in red. These errors are being brought to the attention of the Patent and Trademark Office so that it may correct its records.

Respectfully submitted,

James A. Oliff
Registration No. 27,075

Jesse O. Collier
Registration No. 53,839

JAO:JOC/yxm

Date: October 17, 2005

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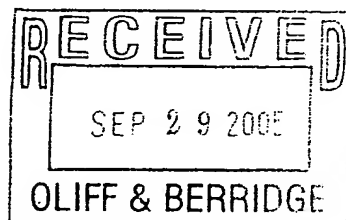


UNITED STATES PATENT AND TRADEMARK OFFICE

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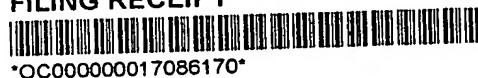
APPL NO.	FILING OR 371 (c) DATE	ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO	DRAWINGS	TOT CLMS	IND CLMS
10/529,466	03/29/2005 5/2/2005	2812	900	123373	11	11	2

25944
 OLIFF & BERRIDGE, PLC
 P.O. BOX 19928
 ALEXANDRIA, VA 22320



CONFIRMATION NO. 8082

FILING RECEIPT



OC000000017086170

Date Mailed: 09/28/2005

Receipt is acknowledged of this regular Patent Application. It will be considered in its order and you will be notified as to the results of the examination. Be sure to provide the U.S. APPLICATION NUMBER, FILING DATE, NAME OF APPLICANT, and TITLE OF INVENTION when inquiring about this application. Fees transmitted by check or draft are subject to collection. Please verify the accuracy of the data presented on this receipt. If an error is noted on this Filing Receipt, please mail to the Commissioner for Patents P.O. Box 1450 Alexandria Va 22313-1450. Please provide a copy of this Filing Receipt with the changes noted thereon. If you received a "Notice to File Missing Parts" for this application, please submit any corrections to this Filing Receipt with your reply to the Notice. When the USPTO processes the reply to the Notice, the USPTO will generate another Filing Receipt incorporating the requested corrections (if appropriate).

Applicant(s)

Sadayoshi Horii, Tokyo, JAPAN;
 Hironobu Miya, Tokyo, JAPAN;

Assignment For Published Patent Application

Hitachi Kokusai Electronic, Inc., Nakano-ku, Tokyo, JAPAN

Power of Attorney: The patent practitioners associated with Customer Number 25944.

Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP03/13606 10/24/2003

Foreign Applications

JAPAN 2002-316154 10/30/2002

Projected Publication Date: 12/29/2005

Non-Publication Request: No

Early Publication Request: No

Title

~~Method for manufacturing semiconductor device and substrate processing system~~

~~MANUFACTURING METHOD OF SEMICONDUCTOR DEVICE AND SUBSTRATE~~

Preliminary Class

438

PROCESSING APPARATUS

PROTECTING YOUR INVENTION OUTSIDE THE UNITED STATES

Since the rights granted by a U.S. patent extend only throughout the territory of the United States and have no effect in a foreign country, an inventor who wishes patent protection in another country must apply for a patent in a specific country or in regional patent offices. Applicants may wish to consider the filing of an international application under the Patent Cooperation Treaty (PCT). An international (PCT) application generally has the same effect as a regular national patent application in each PCT-member country. The PCT process **simplifies** the filing of patent applications on the same invention in member countries, but **does not result** in a grant of "an international patent" and does not eliminate the need of applicants to file additional documents and fees in countries where patent protection is desired.

Almost every country has its own patent law, and a person desiring a patent in a particular country must make an application for patent in that country in accordance with its particular laws. Since the laws of many countries differ in various respects from the patent law of the United States, applicants are advised to seek guidance from specific foreign countries to ensure that patent rights are not lost prematurely.

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Applicants may wish to consult the USPTO booklet, "General Information Concerning Patents" (specifically, the section entitled "Treaties and Foreign Patents") for more information on timeframes and deadlines for filing foreign patent applications. The guide is available either by contacting the USPTO Contact Center at 800-786-9199, or it can be viewed on the USPTO website at <http://www.uspto.gov/web/offices/pac/doc/general/index.html>.

For information on preventing theft of your intellectual property (patents, trademarks and copyrights), you may wish to consult the U.S. Government website, <http://www.stopfakes.gov>. Part of a Department of Commerce initiative, this website includes self-help "toolkits" giving innovators guidance on how to protect intellectual property in specific countries such as China, Korea and Mexico. For questions regarding patent enforcement issues, applicants may call the U.S. Government hotline at 1-866-999-HALT (1-866-999-4158).

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